

Special Issue

Controllable Preparation and Application of Metal Compounds

Message from the Guest Editors

This special issue on “Controllable Preparation and Application of Metal compounds” aims to gather the important developments related to this rapidly growing fields of metal compounds, such as the structural design and precise preparation methods of metal compounds, defect and interface engineering, cost-effective material synthesis techniques, as well as the applications of metal compounds in catalysis, batteries, detectors, ceramics and other fields.

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